

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of

Applicant : Gurtej S. Sandhu  
Serial No. : 10/765,314  
Filed : January 27, 2004  
Title : ATOMIC LAYER DEPOSITION WITH POINT OF USE GENERATED  
REACTIVE GAS SPECIES  
Docket : MIO 0092 NA  
Art Unit : 1762  
Confirm. No. : 9407

EFS WEB ELECTRONIC SUBMISSION  
October 26, 2007

MAIL STOP AMENDMENT  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

**PRELIMINARY AMENDMENT**

Please preliminarily amend this application to place it in better condition for examination. Consideration of the present application is respectfully requested in light of the amendments below, which include, in order of appearance, beginning on separate sheets:

- Amendments to the Claims; and
- Remarks.